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# INFORMATION DISCLOSURE STATEMENT BY APPLICANT

ATTORNEY'S DKT No.

015290-506

APPLICATION No.

09/820,692

APPLICANT

Ting CHIEN et al.

FILING DATE

March 30, 2001

GROUP

1765

JUL 26 2001

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## U.S. PATENT DOCUMENTS

| Examiner<br>Initials | Patent Document |                         | Name of Patentee or Applicant<br>of Cited Document | Date of Publication<br>(MM-DD-YYYY) |
|----------------------|-----------------|-------------------------|--|-------------------------------------|
|                      | Number          | Kind Code<br>(if known) |  |                                     |
| K-cc                 | 5,338,399       | —                       | Yanagida   | 08/16/94                            |
| K-cc                 | 5,366,590       | —                       | Kadomura   | 11/22/94                            |
| K-cc                 | 5,376,228       | —                       | Yanagida   | 12/27/94                            |
| K-cc                 | 5,503,901       | —                       | Sakai et al.                                       | 04/02/96                            |
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| K-cc                 | 5,786,276       | —                       | Brooks et al.                                      | 07/28/98                            |
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| K-cc                 | 6,066,566       | —                       | Naeem et al.                                       | 05/23/00                            |
| K-cc                 | 6,074,959       | —                       | Wang et al.  | 06/13/00                            |
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| K-cc                 | 6,143,641       | —                       | Kitch  | 11/07/00                            |
| K-cc                 | 6,153,514       | —                       | Wang et al.  | 11/28/00                            |
| K-cc                 | 6,156,642       | —                       | Wu et al.  | 12/05/00                            |
| K-cc                 | 6,159,862       | —                       | Yamada et al.                                      | 12/12/00                            |
| K-cc                 | 6,174,451       | —                       | Hung et al.  | 01/16/01                            |
| K-cc                 | 6,183,655       | —                       | Wang et al.  | 02/06/01                            |

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| Examiner<br>Initials | Foreign Patent Document |                         | Country | Date of Publication<br>(MM-DD-YYYY) | Translation |    |
|----------------------|-------------------------|-------------------------|---------|-------------------------------------|-------------|----|
|                      | Number                  | Kind Code<br>(if known) |         |                                     | Yes         | no |
|                      |                         |                         |         |                                     |             |    |
|                      |                         |                         |         |                                     |             |    |

## NON PATENT LITERATURE DOCUMENTS

|                    |  |                 |        |
|--------------------|--|-----------------|--------|
| Examiner Initials  | Include name of author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.  |                 |        |
| K-c-c              | "A Novel Plasma Chemistry for Highly Selective Oxide Etch" by Raymond Hung, Jerry Pender, Betty Tang, Chunchi Cui, Hongching Shan, Keiji Horioka and Yan Ye, Mike Rice, 1999 Dry Process Symposium, pgs. 33-36, Applied Materials, Inc., Sunnyvale, CA, USA. |                 |        |
|                    |  |                 |        |
| Examiner Signature | Ting-Chien CHEN  | Date Considered | 4-3-02 |


EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. SEND TO: Assistant Commissioner for Patents, Washington, D.C. 20231.

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09/820,692

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| Examiner<br>Initials | Foreign Patent Document |                         | Country | Date of Publication<br>(MM-DD-YYYY) | Translation |    |
|----------------------|-------------------------|-------------------------|---------|-------------------------------------|-------------|----|
|                      | Number                  | Kind Code<br>(if known) |         |                                     | Yes         | no |
| fcc                  | WO 01/68939             | —                       | WIPO    | 09/20/2001                          | —           | —  |
|                      |                         |                         |         |                                     |             |    |

|                   |   |
|-------------------|---|
| Examiner Initials | Include name of author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published. |
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|-----------------------|-------------------------|--------------------|--------|
| Examiner<br>Signature | <i>K. H. - CL - CLM</i> | Date<br>Considered | 4-3-02 |
|-----------------------|-------------------------|--------------------|--------|